INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

AUG 10 2001 JC42 PATENT & TRADEMARK OFFICE

Docket Number (Optional)	Application Number
00-SM5-408 (A[illegible]0001)	09/864,003
Applicant(s)	
QINGYUAN HAN, ET AL.	
Filing Date	**Group Art Unit**
May 23, 2001	

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
AH	1	5,332,653	07/26/1994	CULLEN et al.	430	323	07/01/1992
AH	2	6,030,901	02/29/2000	HOPPER et al.	438	711	06/24/1999

TC 1700 MAIL ROOM
RECEIVED
AUG 14 2001

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation YES	Translation NO

OTHER DOCUMENTS *(Including Author, Title, Date, Pertinent Pages, Etc.)*

AH	3	Laura Peters, Senior Editor,"Low-k Dielectrics: Will Spin-On or CVD Prevail?" www.semiconductor.net., June 2000

EXAMINER	A. MARMOFF	DATE CONSIDERED	3/23/03

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.